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Dkt. 05158

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

PCT

INGO SCHWIRTLICH et al

Serial No.: 10/562,851

Filed: December 29, 2005

For: METHOD FOR FORMING A STRUCTURE

INFORMATION DISCLOSURE STATEMENT

Honorable Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

Sir:

Attached hereto is a Form PTO-1449 listed references cited in the corresponding PCT and EP applications, together with copies of non-U.S. patent references.

Respectfully submitted,

Ira J. Schultz
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Form PTO-1449

ATTY DOCKET NO.

05158

APPLICATION NO.

10/562851

**INFORMATION DISCLOSURE CITATION
IN AN APPLICATION**

(Use several sheets if necessary)

APPLICANT

Ingo Schwirtlich et al

FILING DATE

December 29, 2005

GROUP

U.S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER							DATE	NAME	CLASS	SUB CLASS	FILING DATE IF APPROPRIATE
	4	4	5	7	8	6	1	07/1984	Desmarais			
	5	6	5	3	9	1	8	08/1997	Towlson			
	6	3	1	2	8	6	4	11/2001	Osamu et al			
	6	3	2	2	6	2	0	11/2001	Xiao Yue			
	2001	0	2	9	9	7	7	10/2001	Oya			

FOREIGN PATENT DOCUMENTS

	DOCUMENT NUMBER							DATE	COUNTRY	CLASS	SUB CLASS	TRANSLATION	
												YES	NO
	93	2	4	9	3	4		12/93	WO				
	63	2	6	8	7	7	3	11/1988	JP				

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)

	Lenkeit et al, High Quality Screen-Printed and Fired-Through Silicon Nitride etc., May 2000, Commission of the European Communities, pp 1332-1335.
	Horzel et al, "Screen-Printed Rapid Thermal Processed (RTP) Selective emitter Solar Cells etc., May 2000, Commission of the European Communities, pp 1087-1090.

EXAMINER

DATE CONSIDERED

EXAMINER: Initial if citation considered, whether or not citation is in conformance with M.P.E.P. 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.